
Design and Measurement of On-chip di/dt Detector Circuit for Power Supply Line

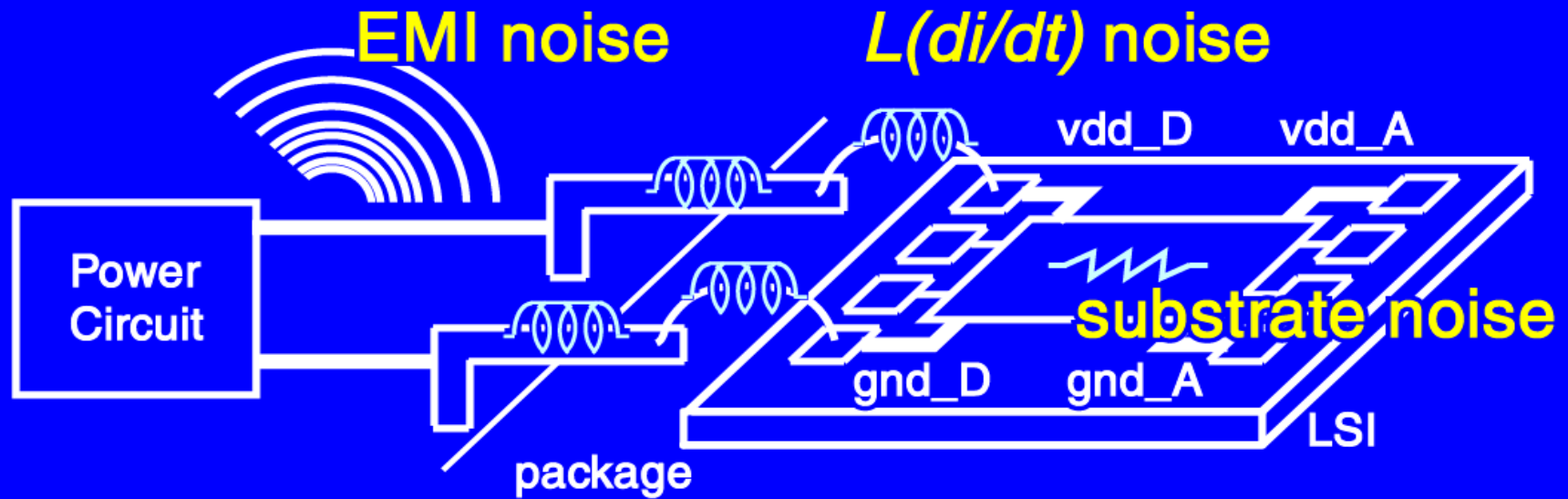
Toru Nakura[#], Makoto Ikeda^{*}, Kunihiro Asada^{*}



*[#]Dept. of Electronic Engineering,
^{*}VLSI Design and Education Center,
University of Tokyo, Tokyo, Japan*

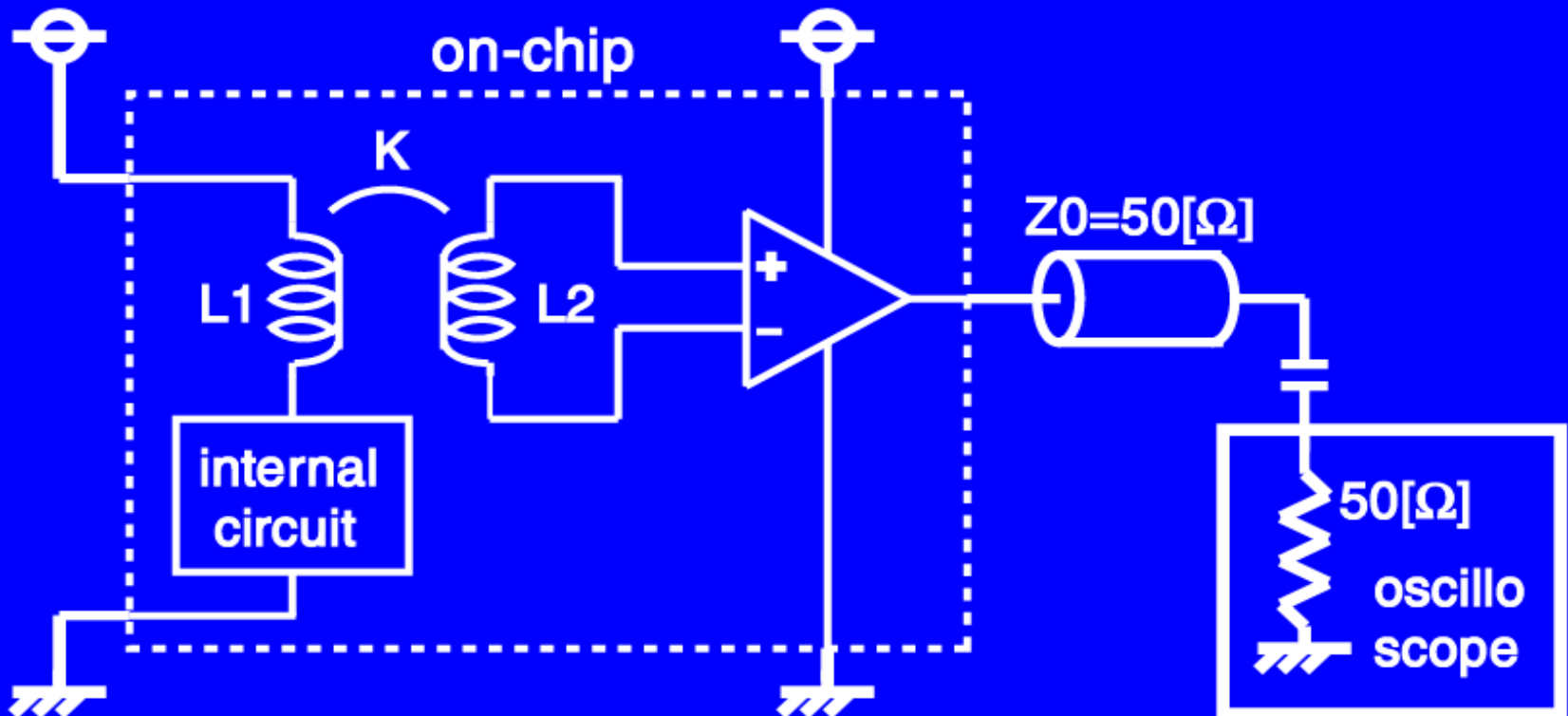
Background – di/dt and SI

- Power supply noise : $L(di/dt)$, RI noise
- EMI noise : caused by di/dt
- Substrate noise : related to power noise
- Need to measure di/dt

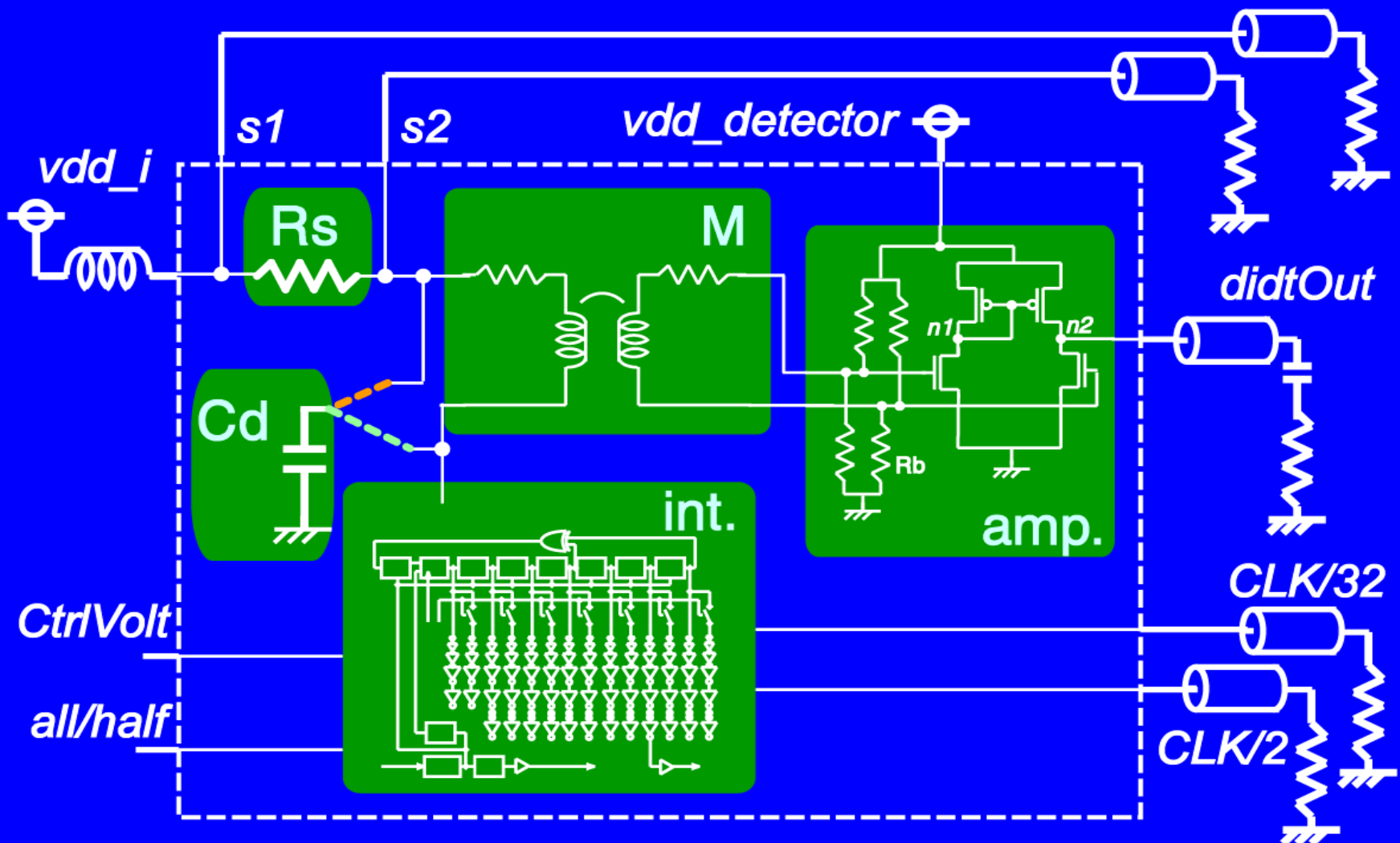


Block Diagram

- L2 picks up the di/dt , induce the voltage
- Amplifier amplifies/output the voltage

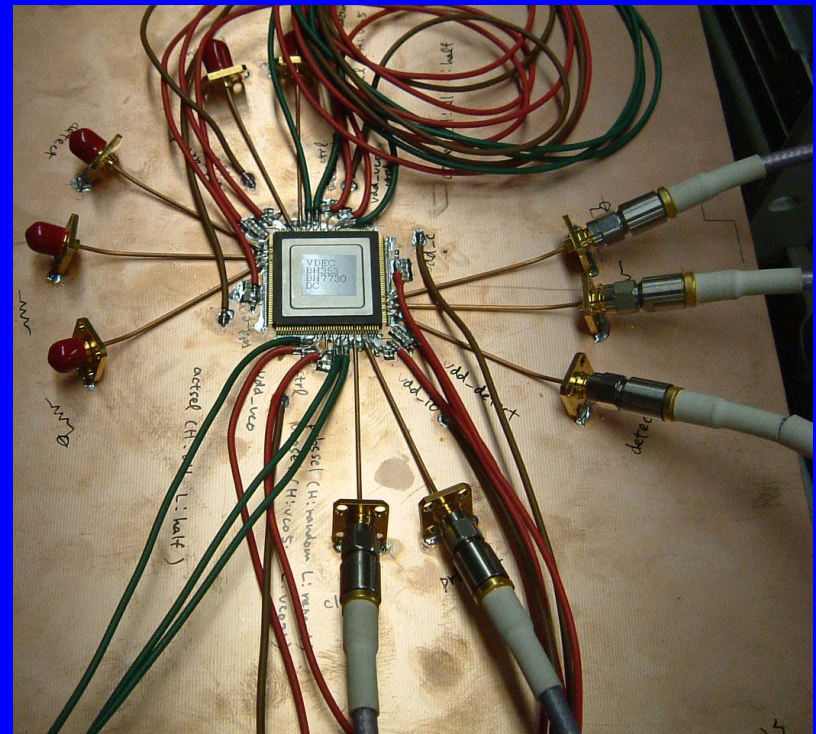
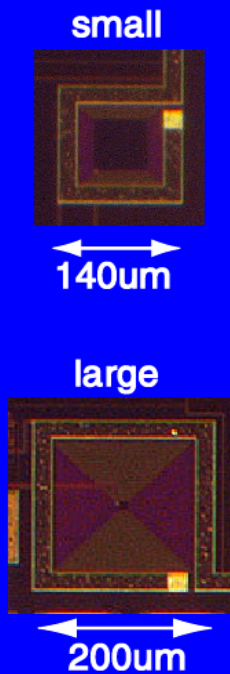
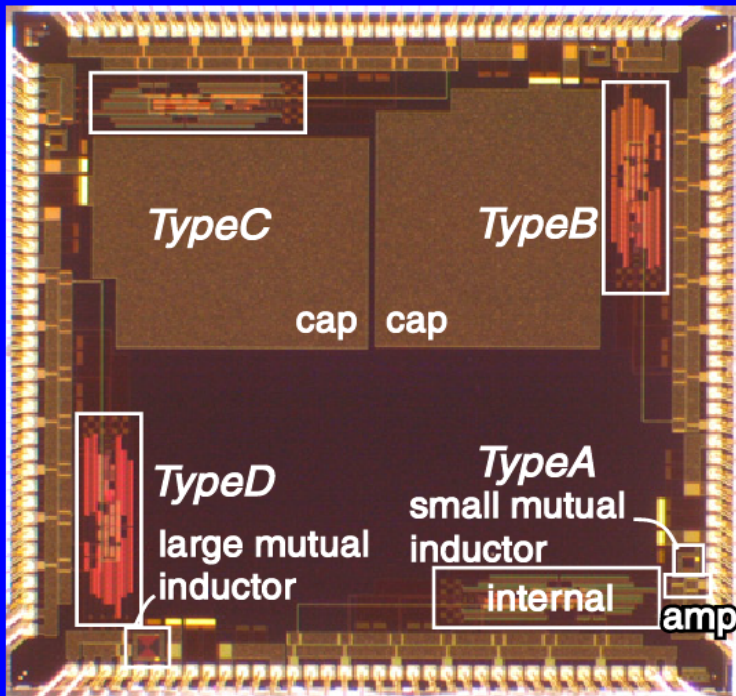


Whole Circuit / Meas. Setup

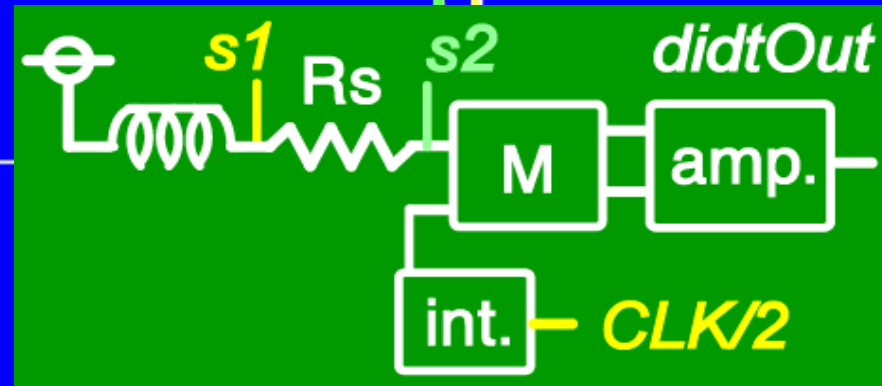
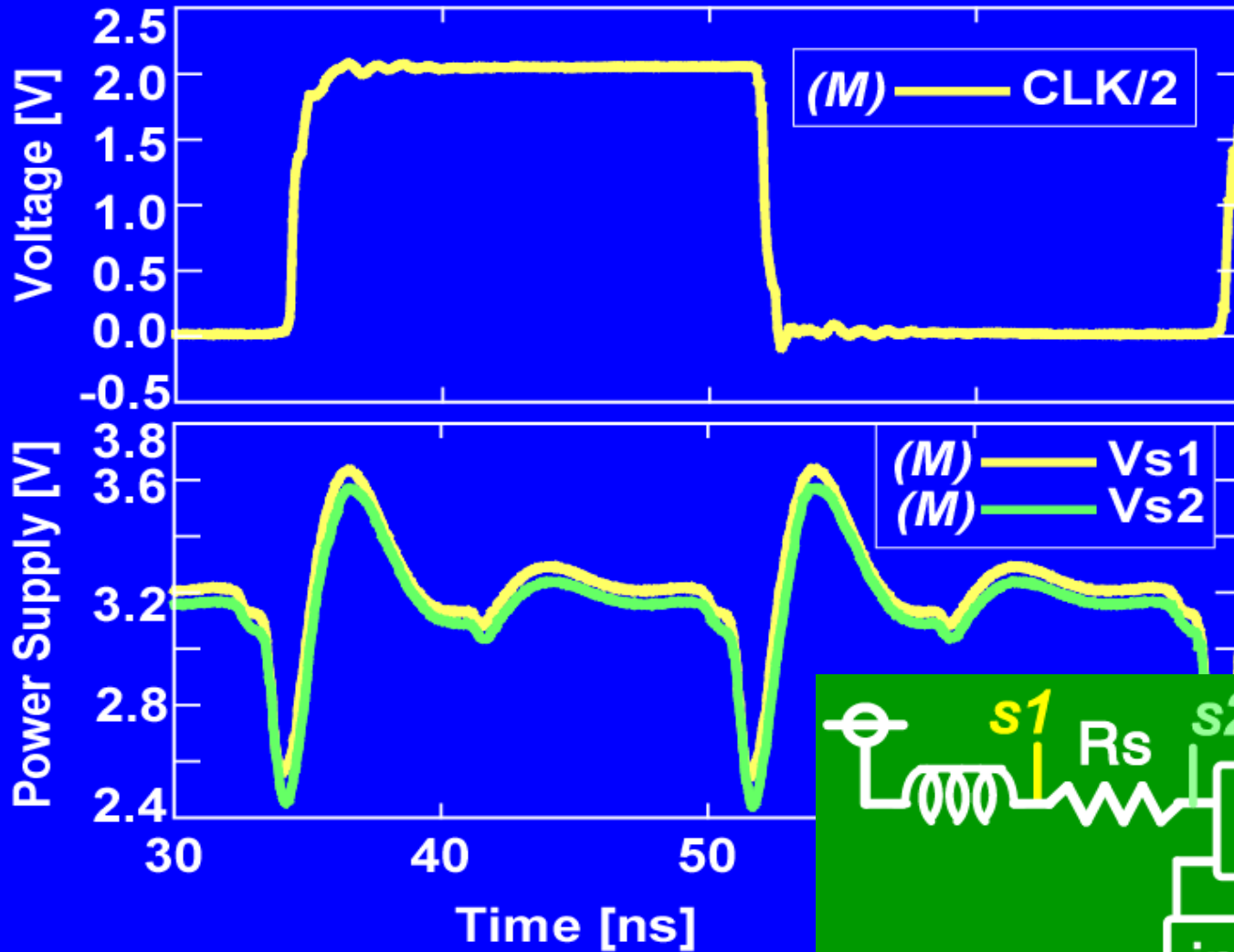


Chip Photograph

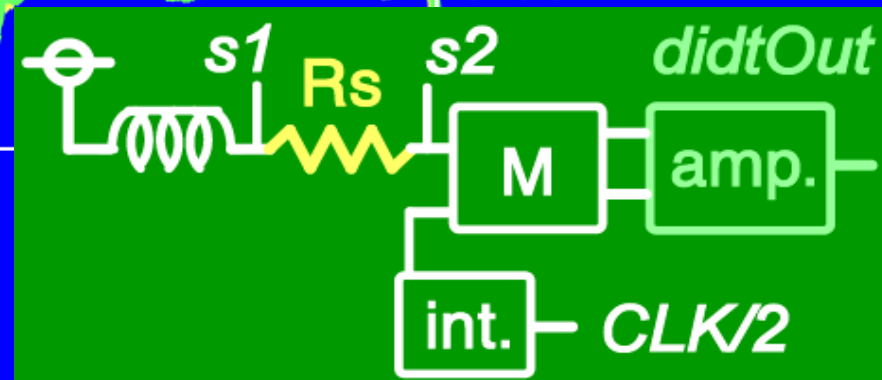
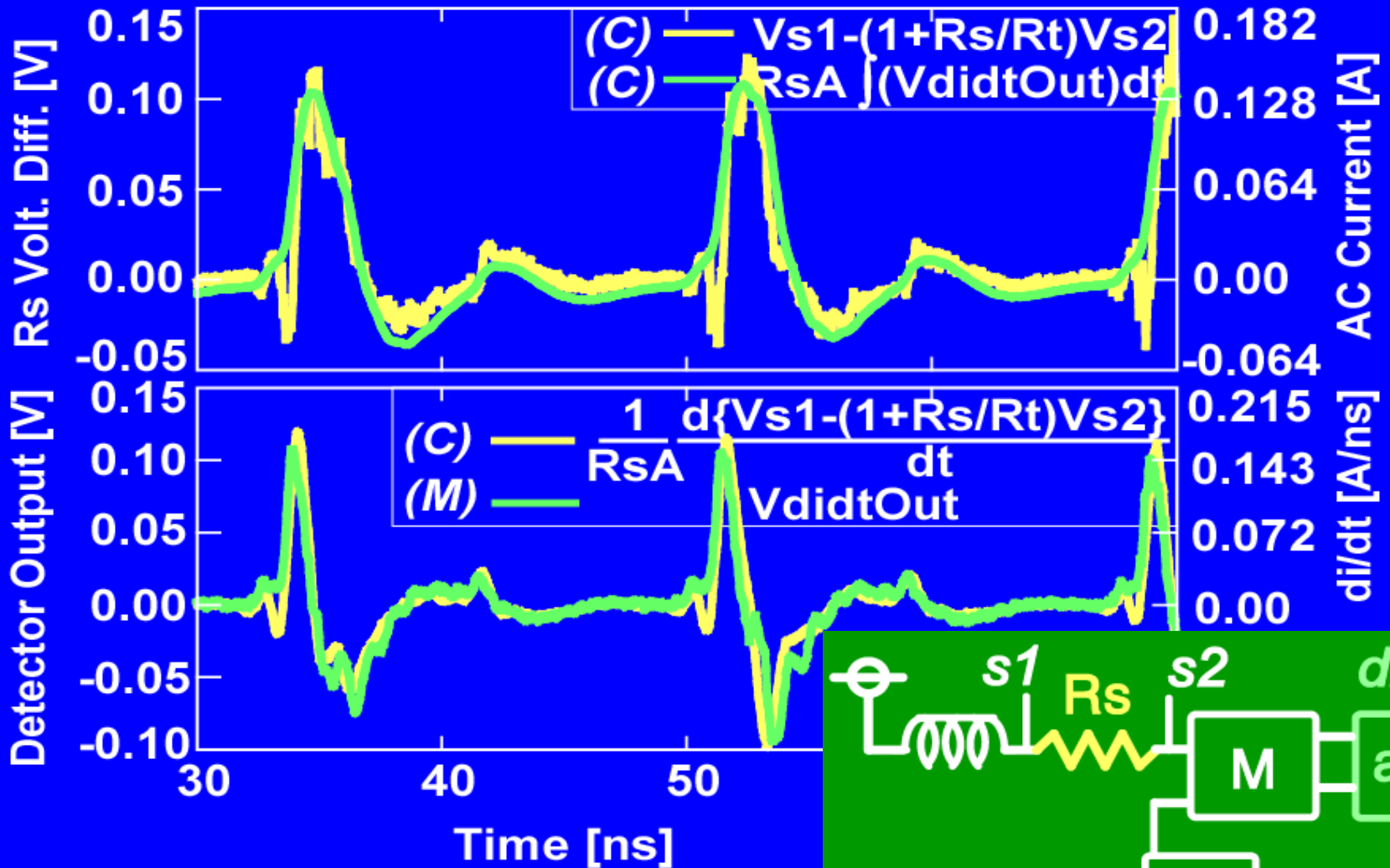
- 0.35um 3ML 2P standard CMOS
- The chip is mounted on a Cu board



Waveforms #1



Waveforms #2



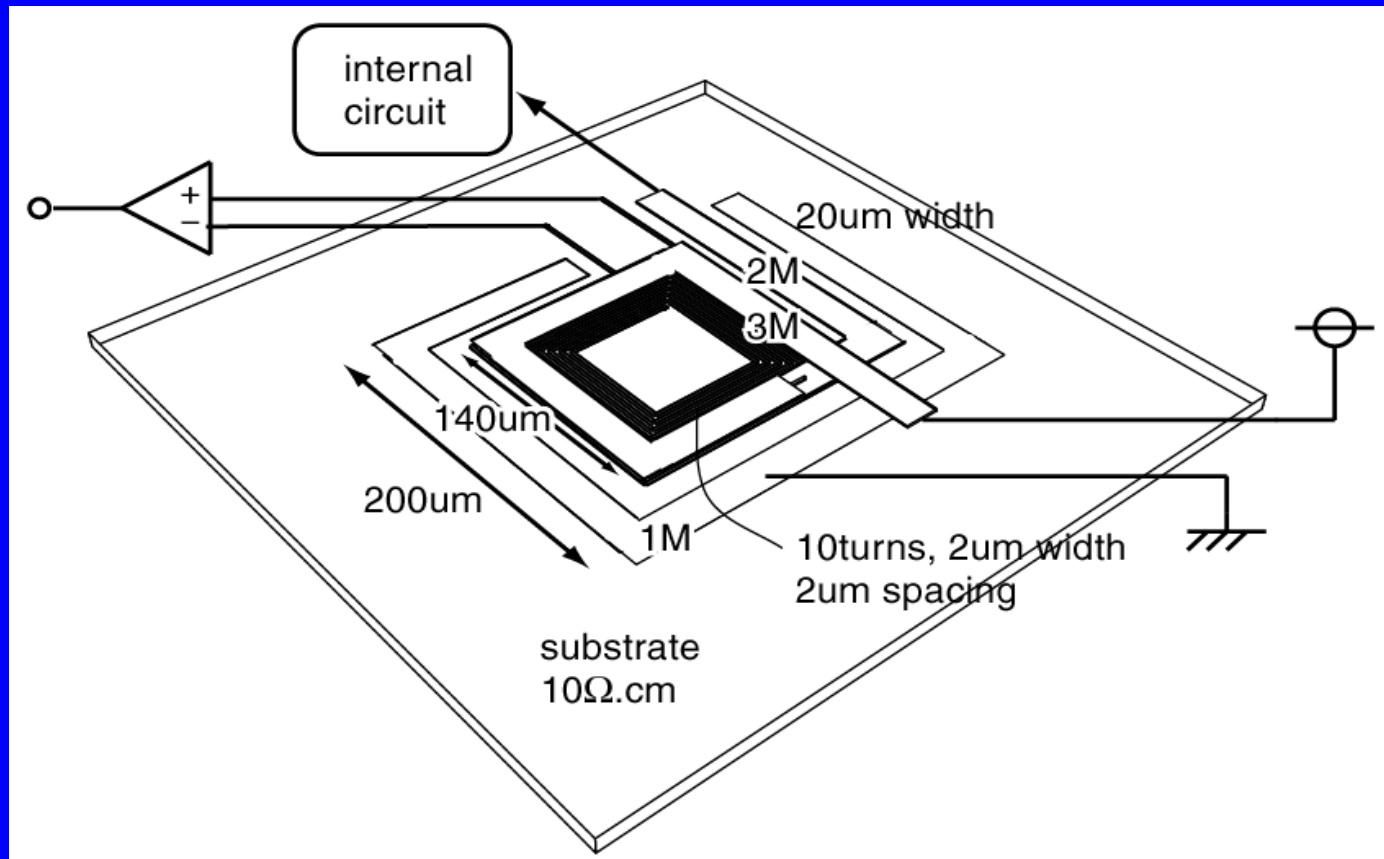
Summary

- On-chip di/dt detector is demonstrated
- It consists of a power supply line, underlying spiral inductor, an amplifier
- di/dt waveforms obtained from the di/dt detector and the resistor agree well
- Current waveform can be calculated by integrating the detector output by time

Small Slides

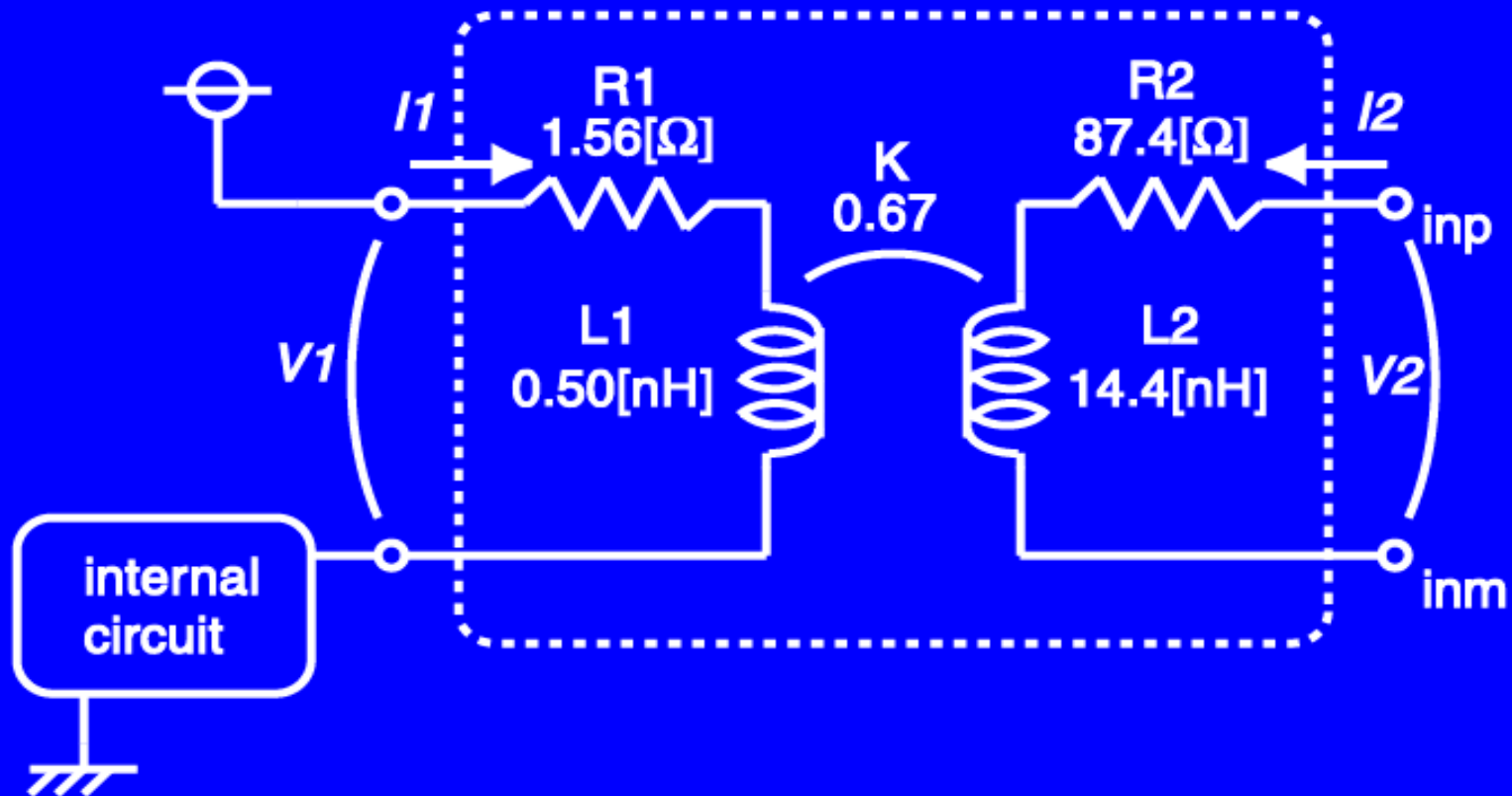
Mutual Inductor

- 0.35 μm , 3ML standard CMOS process



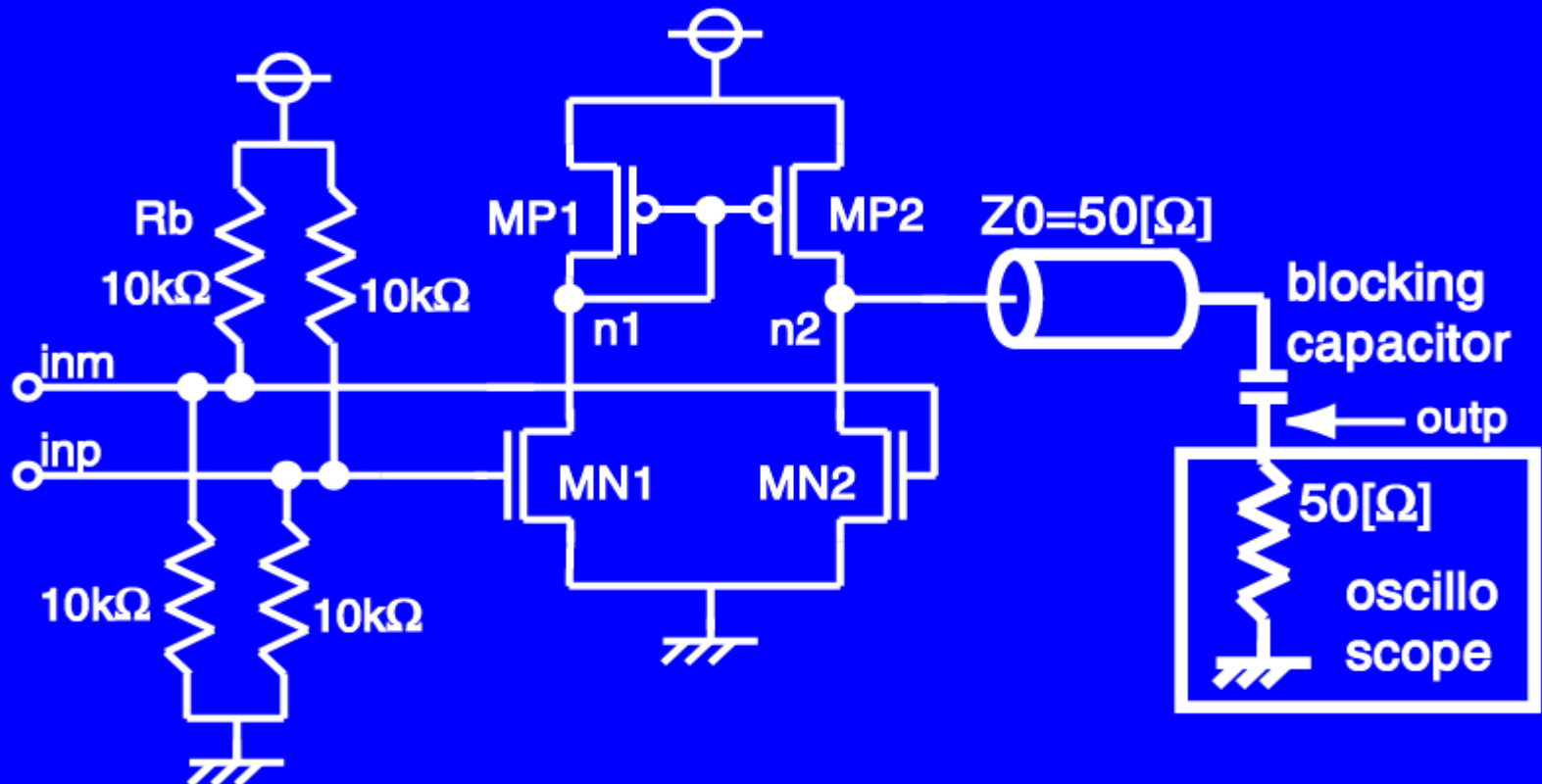
Equivalent Circuit

- Extracted by FastHenry

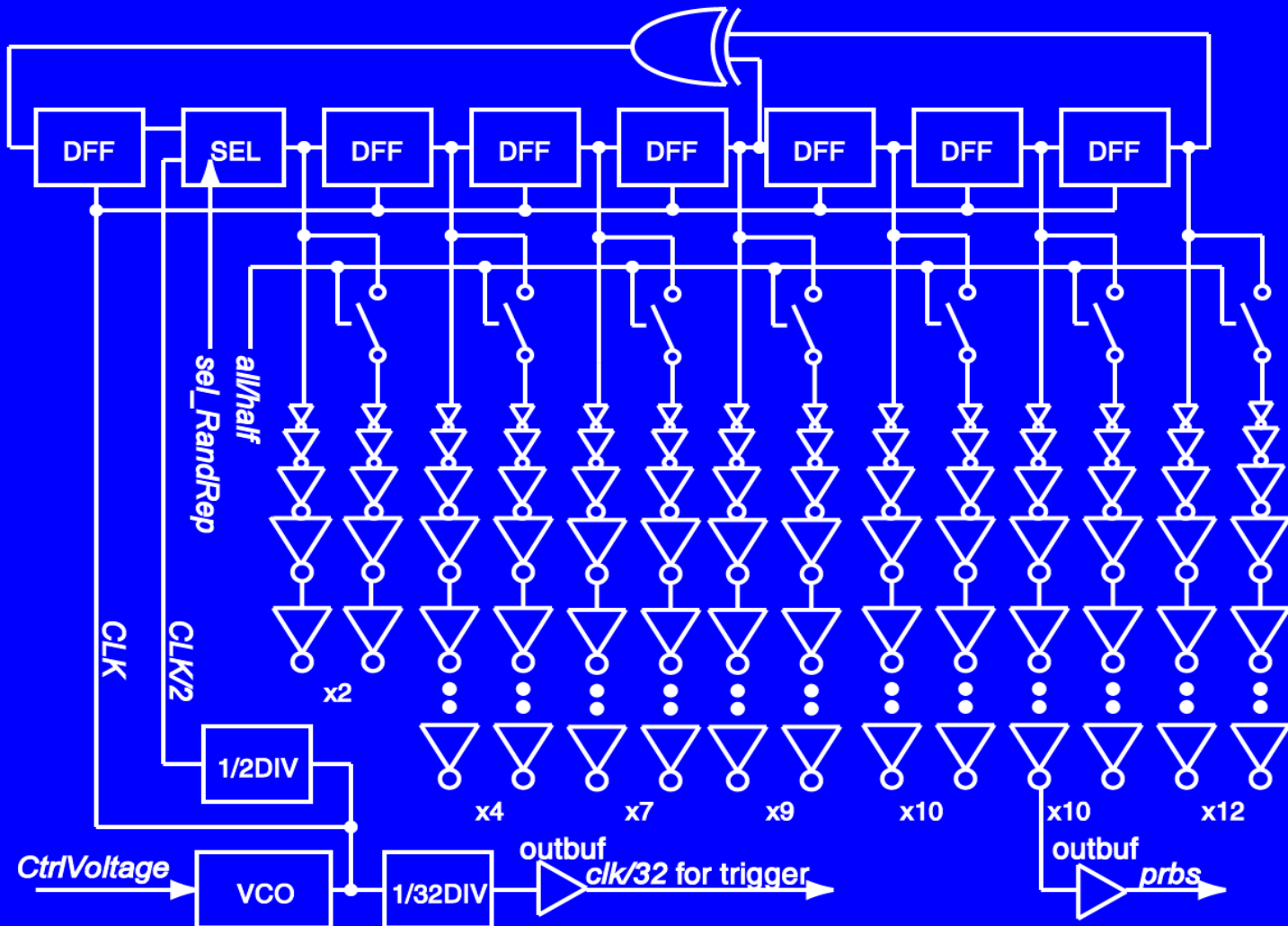


Amplifier/Output buffer

- Gain: 0.39, $f_{\text{cut-off}}$: 2.2GHz
output linearly: $\pm 0.35\text{V}$



Internal Circuit as Noise Source



Equations

$$V_2 = K\sqrt{L_1L_2} \frac{di_1}{dt}$$

$$V_{s1} - \left(1 + \frac{R_s}{R_t}\right) V_{s2} = R_s I_1$$

$$V_{didtOut} = G V_2 = GK\sqrt{L_1L_2} \frac{di_1}{dt}$$

$$\frac{di_1}{dt} = \frac{1}{GK\sqrt{L_1L_2}} V_{didtOut} = A_{v2didt} V_{didtOut}$$

$$A_{v2didt} = \frac{1}{GK\sqrt{L_1L_2}}$$

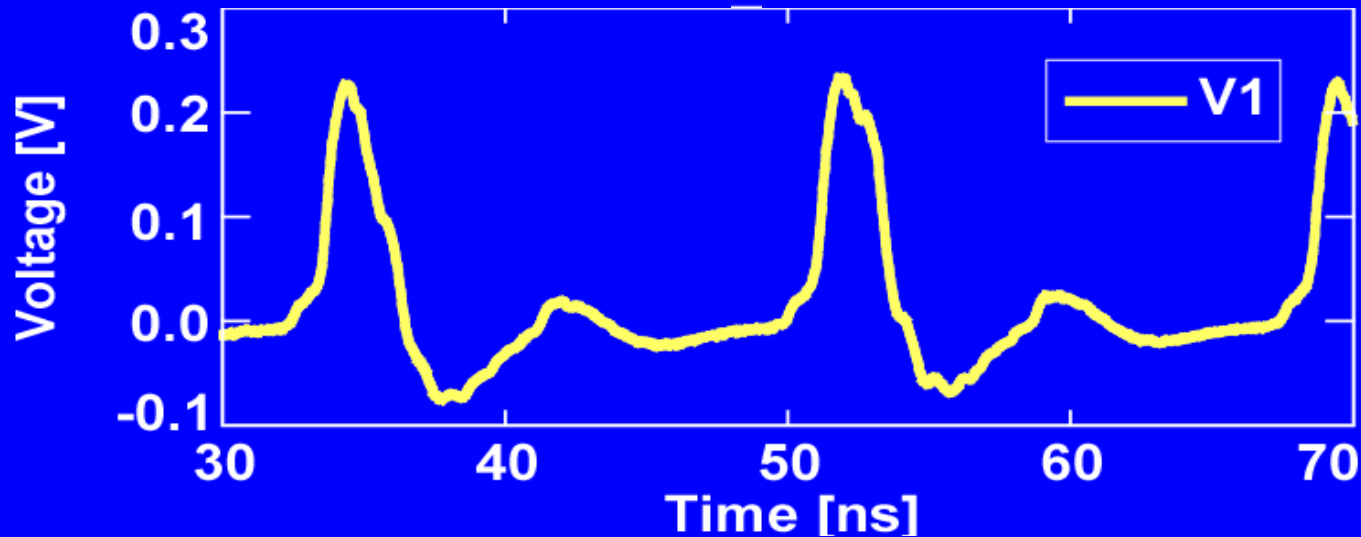
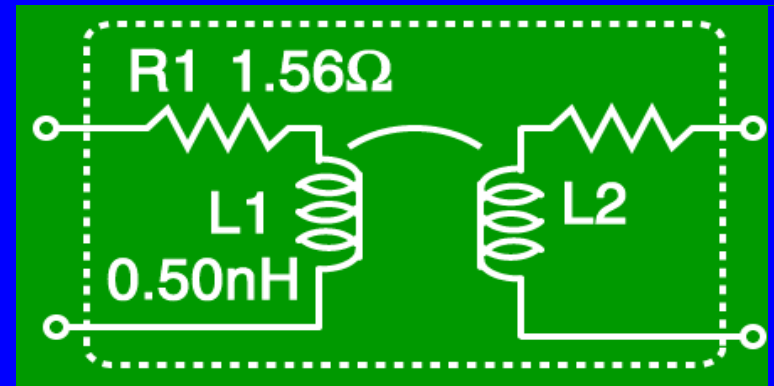
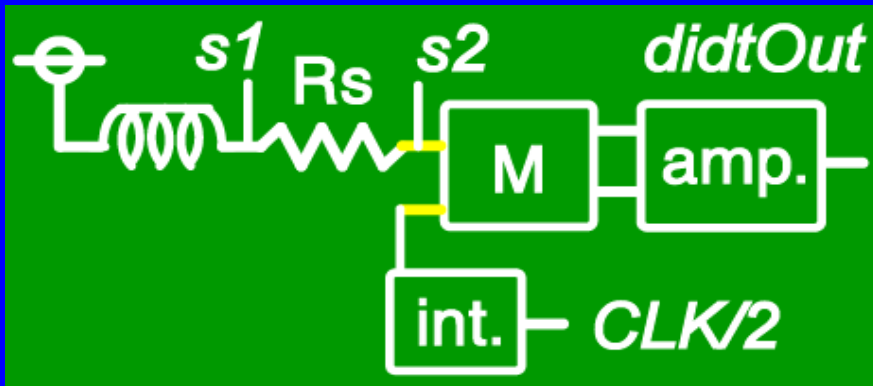
$$\frac{di_1}{dt}_{range} = A_{v2didt} V_{amp_outRange_lin}$$

$$I_1 = A_{v2didt} \int V_{didtOut} dt + C$$

$$\frac{di_1}{dt}_{res} = A_{v2didt} V_{didtOut_res}$$

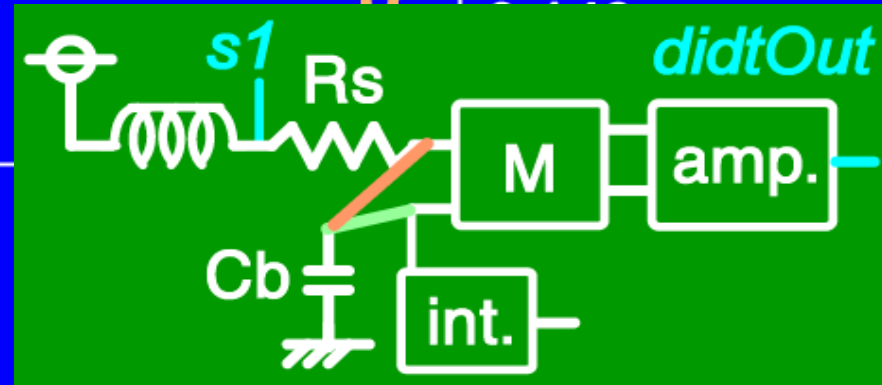
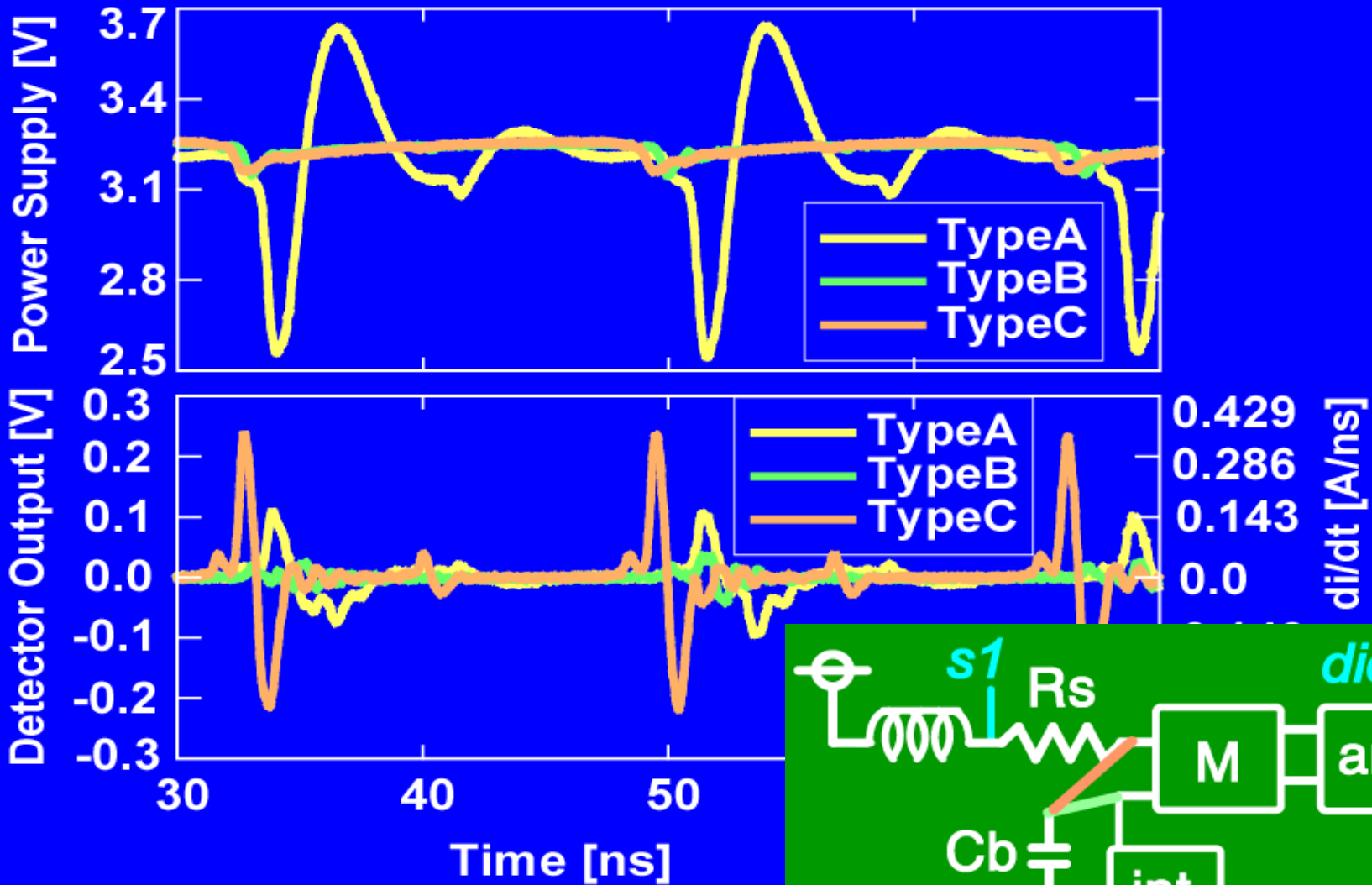
- $L_1=0.5\text{nH}$, $L_2=14.4\text{nH}$, $K=0.67$, $G=0.385$,
- $R_s=0.78\Omega$, $R_t=50\Omega$
- $V_{amp_lin}=\pm 0.35\text{V}$, $di/dt_range=\pm 0.5\times 10^9\text{A/s}$

di/dt Detector Impedance



- Multi-layer metal, wider line or low sensitivity can reduce the voltage drop

Decoupling Capacitor Effects



Activation, M dependence

